

**RESPONSE UNDER 37 CFR 1.116  
EXPEDITED PROCEDURE  
EXAMINING GROUP 1711**

**PATENT**  
Attorney Docket No. 203924  
Client Reference No. 20721-RCE-RCE

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:

Kodama et al.

Application No. 09/502,834

Art Unit: 1711

Examiner: D. Truong

Filed: February 11, 2000

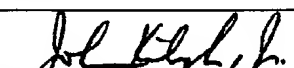
For: POLYBENZAZOLE ARTICLE AND  
PRODUCTION METHOD THEREOF

**SUPPLEMENTAL RESPONSE TO OFFICE ACTION**

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated January 21, 2004, please enter the following amendments and consider the following remarks. Applicants note that this response replaces the "Response to Office Action," dated April 21, 2004, which was not entered per the Advisory Action, dated May 13, 2004.

<b>CERTIFICATE OF MAILING UNDER 37 CFR 1.10</b>			
I hereby certify that this Supplemental Response to Office Action and all accompanying documents are being deposited with the United States Postal Service on June 21, 2004, in an envelope as "EXPRESS MAIL POST OFFICE TO ADDRESSEE" service under 37 CFR 1.10, Mailing Label Number EV 335717639 US, addressed to: Mail Stop AF, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.			
Name (Print/Type)	John Kilyk, Jr.		
Signature		Date	June 21, 2004

6/24/2004 AWONDAF1 00000010 121216 09502834

FC:1252 420.00 DA

*OK to enter*

*7/13/04*

CLAIM AMENDMENTS

1. (Currently Amended) A polybenzazole article superior in light resistance, which comprises a polybenzazole and a light-resisting agent that allows for a regular reflectance of the article of not more than 30% in not less than 30% of the wavelength region of from 450 nm to 700 nm, wherein the light-resisting agent is at least one member selected from the group consisting of ~~aniline, o-phenylenediamine, m-phenylenediamine, p-phenylenediamine, o-aminophenol, m-aminophenol, p-aminophenol~~, 2-amino-4-nitrophenol, 2-aminophenol-4-sulfonamide, and 1,8-diaminonaphthalene.

2. (Original) The polybenzazole article of claim 1, wherein the light-resisting agent allows for a regular reflectance of the article of not more than 20% in not less than 10% of the wavelength region of from 450 nm to 700 nm.

3. (Original) The polybenzazole article of claim 1, which has a strength of not less than 35 g/d.

4. (Canceled)

5. (Canceled)

6. (Original) The polybenzazole article of claim 1, wherein the light-resisting agent is contained in a proportion of 0.01 to 20% by weight of the article.

7. (Canceled)

8. (Canceled)